

# Hangyang Chen

## List of Publications by Year in descending order

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11  
papers

129  
citations

1684188

5  
h-index

1281871

11  
g-index

11  
all docs

11  
docs citations

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times ranked

195  
citing authors

#	ARTICLE	IF	CITATIONS
1	Regulating the Valence Level Arrangement of High-Al-content AlGa <sub>N</sub> Quantum Wells Using Additional Potentials with Mg Doping. <i>Physical Chemistry Chemical Physics</i> , 2022, , .	2.8	1
2	Integral Monolayer-Scale Featured Digital-Alloyed AlN/GaN Superlattices Using Hierarchical Growth Units. <i>Crystal Growth and Design</i> , 2019, 19, 1720-1727.	3.0	19
3	Modification of strain and optical polarization property in AlGa <sub>N</sub> multiple quantum wells by introducing ultrathin AlN layer. <i>AIP Advances</i> , 2019, 9, .	1.3	2
4	Improved Characteristics of AlGa <sub>N</sub> -Based Deep Ultraviolet Light-Emitting Diodes with Superlattice p-Type Doping. <i>IEEE Photonics Journal</i> , 2017, 9, 1-7.	2.0	21
5	High density GaN/AlN quantum dots for deep UV LED with high quantum efficiency and temperature stability. <i>Scientific Reports</i> , 2014, 4, 5166.	3.3	38
6	Vacuum Rabi Splitting of Excitonâ€“Polariton Emission in an AlN Film. <i>Scientific Reports</i> , 2013, 3, 3551.	3.3	10
7	Symmetrically abrupt GaN/AlGa <sub>N</sub> superlattices by alternative interfaceâ€“interruption scheme. <i>Journal of Materials Research</i> , 2013, 28, 716-722.	2.6	6
8	Control of two-dimensional growth of AlN and high Al-content AlGa <sub>N</sub> -based MQWs for deep-UV LEDs. <i>AIP Advances</i> , 2013, 3, 052103.	1.3	5
9	Structural properties of InN films grown in different conditions by metalorganic vapor phase epitaxy. <i>Journal of Materials Research</i> , 2011, 26, 775-780.	2.6	4
10	Origins and suppressions of parasitic emissions in ultraviolet light-emitting diode structures. <i>Journal of Materials Research</i> , 2010, 25, 1037-1040.	2.6	4
11	Enhancement of p-type conductivity by modifying the internal electric field in Mg- and Si-Î²-codoped Al <sub>x</sub> Ga <sub>1-<math>\tilde{x}</math></sub> N/Al <sub>y</sub> Ga <sub>1-<math>\tilde{y}</math></sub> N superlattices. <i>Applied Physics Letters</i> , 2009, 95, .	3.3	19